Electronic Acknowledgement Receipt				
EFS ID:	1207286			
Application Number:	10672778			
Confirmation Number:	9717			
Title of Invention:	Atomic layer deposition (ALD) method with enhanced deposition rate			
First Named Inventor:	Chih-Ta Wu			
Customer Number:	47390			
Filer:	Daniel R. McClure			
Filer Authorized By:				
Attorney Docket Number:	252016-3000			
Receipt Date:	19-SEP-2006			
Filing Date:	26-SEP-2003			
Time Stamp:	08:24:06			
Application Type:	Utility			
International Application Number:				
Payment information:				
Submitted with Payment	yes			
Payment was successfully received in RAM	\$50			

File Listing:					
Document Document	Document Description	File Name	File Size(Bytes)	Multi	Pages

Part

879

RAM confirmation Number

Number

Total Files Size (in bytes):				8132			
Information	:						
Warnings:							
1	Fee Worksheet (PTO-875)	fee-info.pdf	8132	no	2		

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New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.